J.C. PATENTS

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January 4, 2006

| Atty Docket No. | : | JCLA10375-D |
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| Appl. No. | : | 10/805,933 |
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BY FACSIMILE ONLY

| Fax No. | ; | 571-273-8300 |
|------------|---|---|
| Attention | : | EXAMINER: LUU, CHUONG A. |
| Group Unit | : | 2825 |
| From | : | Jiawei Huang, Reg. No. 43,330 |
| MESSAGE | : | Enclosed herewith is an Amendment in 4 pages. |

Sir:

I hereby certify that this correspondence is being facsimile transmitted to the Patent and Trademark Office on <u>January 4</u>, 2006 at the above indicated fax number.

Sign by:

Michelle Chang

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Application No.: 10/805,933

JAN 0 4 2006

Docket No.: JCLA10375-D

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Examiner: LUU, CHUONG A

Group Art Unit: 2818

In re PATENT APPLICATION of
Applicants: Yu et al.

Serial No.: 10/805,933
)

Filed: March 22, 2004
)

For: WAFER LEVEL TESTING AND BUMPING PROCESS
)

AMENDMENTS AND RESPONSE TO OFFICE ACTION

Mail Stop Amendment

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

The Office Action mailed on October 26, 2005 has been carefully considered. Applicants respectfully submit the following Amendments and Remarks.